





Patent Application of

Ki Young OH, et al.

Date:

April 25, 2002

Serial No .:

09/835,498

Group Art Unit:

1734

Filed:

April 16, 2001

Examiner:

Matthew J. Song

For:

APPARATUS AND METHOD FOR FORMING ULTRA-THIN

FILM OF A SEMICONDUCTOR DEVICE

Asst. Commissioner for Patents Washington, D.C. 20231

RESPONSE TO RESTRICTION RI REMARKS/ARGUMENT

Applicant responds herein to the Office Action dated April 4, 2002, wherein a restriction has been required to one of two inventions under 35 U.S.C. §121.

Responsive thereto, the applicant elects the Invention I for prosecution on the merits in the present application. This Invention I is reflected in claims 1-4, drawn to an apparatus classified in class 118 subclass 723R.

If this communication is filed after the statutory time period had elapsed and no separate Petition is enclosed, the Commissioner of Patents and Trade-marks is petitioned, under 37 C.F.R. §1.136(a), to extend the time for filing a response to the outstanding Office Action by the number of months which will avoid abandonment under 37 C.F.R. §1.135. The fee under 37 C.F.R. § 1.17 should be charged to our Deposit Account No. 15-0700.

Early and favorable consideration of the present application is earnestly solicited.

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as First Class Mail in an envelope addressed to: Asst. Commissioner for Patents, Washington, D.C. 20231, on April 25, 2002

Max Moskowitz

Name of applicant, assignee or Registered Representative

Signature

April 25, 2002

Date of Signature

Respectfully submitted,

Max Moskowitz

Registration No.: 30,576

OSTROLENK, FABER, GERB & SOFFEN, LLP

1180 Avenue of the Americas

New York, New York 10036-8403

Telephone: (212) 382-0700

MM:cg

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